Contribution ID: 10

Type: Poster

Temperature Dependence of Atomic Structure Around Doped W atom in ZnO thin film studied by photoelectron diffraction

Friday, 1 July 2016 13:25 (1 hour)

Primary authors: Mr FUKAMI, Shun (Nara Institute of Science and Technology); Dr SUZUKI, Taku (National Institute for Materials Science)

Co-authors: Dr MATSUI, Fumihiko (Nara Institute of Science and Technology); Prof. DAIMON, Hiroshi (Nara Institute of Science and Technology (NAIST)); Dr SAKAGUCHI, Isao (National Institute for Materials Science); Dr WATANABE, Ken (National Institute for Materials Science); Dr TAGUCHI, Munetaka (Graduate School of Materials Science, Nara Institute of Science and Technology); Dr MURO, Takayuki (Japan Synchrotron Radiation Research Institute); Dr MATSUSHITA, Tomohiro (Japan Synchrotron Radiation Research Institute); Dr ADACHI, Yuu (National Institute for Materials Science)

Presenter: Mr FUKAMI, Shun (Nara Institute of Science and Technology)

Session Classification: Poster Session

Track Classification: Poster Session